

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Ji Zhu et al.

Ser. No.: 10/599,106

Filing Date: September 19, 2006

Attorney Docket No.: IB-1997

For: METHODS FOR FABRICATION OF
POSITIONAL AND COMPOSITIONALLY
CONTROLLED NANOSTRUCTURES ON
SUBSTRATE

Examiner: Allan W. Olsen
Group Art Unit: 1716
Confirmation No.: 4207

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This is in response to the Restriction Requirement mailed September 14, 2010 for which the time to respond is due on or before the due date of October 14, 2010. Accordingly, this response is timely filed.

REMARKS

Restriction Requirement

The Examiner is requiring restriction under 35 U.S.C. § 121 and 372 to one of the following inventions:

- I. Claims 1-33, drawn to a method of fabricating a nanostructured array;
- II. Claims 34-66, drawn to a method of fabricating a nanostructured array;
- III. Claims 67-99, drawn to a method of fabricating a nanostructured array;
- IV. Claims 100-117, drawn to a sensor device; and,
- V. Claims 118-135, drawn to a nanostructure array.